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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/650,406	08/27/2003	Jong Moon Lee	51876P384	6551
8791	7590 12/12/2005		EXAMINER	
BLAKELY	SOKOLOFF TAYLO	CAO, HUEDUNG X		
12400 WILSHIRE BOULEVARD SEVENTH FLOOR			ART UNIT	PAPER NUMBER
	ES, CA 90025-1030		2821	
			DATE MAILED: 12/12/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	10/650,406	LEE ET AL.			
Office Action Summary	Examiner	Art Unit			
	Huedung X. Cao	2821			
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period we Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	66(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days fill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. & 133)			
Status					
1)⊠ Responsive to communication(s) filed on 14 No	ovember 2005.				
_					
Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims					
<ul> <li>4)  Claim(s) 1-5 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdraw</li> <li>5)  Claim(s) 4-5 is/are allowed.</li> <li>6)  Claim(s) 1-3 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or</li> </ul>		•			
Application Papers					
9)☐ The specification is objected to by the Examiner.					
10)⊠ The drawing(s) filed on <u>27 August 2003</u> is/are: a)⊠ accepted or b) $\Box$ objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
a) Acknowledgment is made of a claim for foreign part   a) All b) Some * c) None of:  1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priori application from the International Bureau * See the attached detailed Office action for a list of	have been received. have been received in Application ty documents have been receive (PCT Rule 17.2(a)).	on No d in this National Stage			
Attachment(s)					
Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary ( Paper No(s)/Mail Dat				
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  Paper No(s)/Mail Date (4)	5) Notice of Informal Pa 6) Other:				

## DETAILED ACTION

## Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-3 are rejected under 35 U.S.C. 103(a) as being unpatentable over OBERSCHMIDT et al. (USP 6,507,321 B2) in view of MURAMOTO et al. (US 6,342,864 B1).

As per claim 1, Oberschmidt teaches "a broadband slot antenna", comprising:
a dielectric layer under which microstrip feedline is formed (Oberschmidt, figure
3, substrate 1 and feedline 4, and column 5, lines 1-5);

ground formed on the dielectric layer and coupled with the microstrip feedline electromagnetically through a slot (Oberschmidt, figure 3, metallic layer 7, the metallic layer 7 is a conductive layer worked as a ground plane; column 3, lines 2-8); and reflection plane placed under the microstrip feedline (Oberschmidt, figure 3, reflector plane14, column 4, lines 35-40, and column 5, lines 18-19) and having an open part with predetermined length and depth in order to prevent board surface waves from being radiated and enhance antenna gain which Oberschmidt does not explicitly disclose. However, Muramoto teaches such reflection plane having an open part with predetermined length and depth is widely use in the art (Muramoto, figures 6, 7A, 7B,

column 4, lines 7-27). It would have been obvious to a person of ordinary skill in the art, to provide Oberschmidt's antenna system with reflector plane having an open part, as taught by Muramoto in order to adjust the directionality created by the slot antenna portion, so that a beam transmitted from or received by the slot antenna portion can be oriented in a desired direction, thus improving the directionality and the F/B ratio (i.e., front to back ratio) thereof.

Claim 2 adds into claim 1 "area of an entrance of the slot is the same as that of a bottom of slot or area of the entrance of the slot different from that of the bottom of the slot" (Oberschmidt, column 3, line 65-column 4, line 20; the slots 2 and 3 have the area of entrance being the same as that of the bottom of slot).

Claim 3 adds into claim 1 "reflection plane is a metal resonator" (Oberschmidt, figure 3, reflector plane14, and column 5, lines 13-14).

## Allowable Subject Matter

- 3. Claims 4-5 are allowed.
- 4. The following is an examiner's statement of reasons for allowance:

Regarding claim 4, Oberschmidt et al. (USP 6507321 B2) discloses a broadband slot antenna, comprising: a dielectric layer under which microstrip feedline is formed; ground formed on the dielectric layer and coupled with the microstrip antenna electromagnetically through a slot; and reflection plane placed under the microstrip feedline in order to prevent board surface waves from being radiated and enhance

Application/Control Number: 10/650,406

Art Unit: 2821

in Control Number. 10/030,40

antenna gain. Oberschmidt, however, fails to teach a baffle layer formed on the ground

Page 4

conductor in order to prevent mutual coupling between the slot antennas. In addition,

the art does not suggest the addition of a baffle layer for preventing mutual coupling

between the slot antennas of a slot array antenna.

Claim 5 is allowed for depending on claim 4.

Any comments considered necessary by applicant must be submitted no later

than the payment of the issue fee and, to avoid processing delays, should preferably

accompany the issue fee. Such submissions should be clearly labeled "Comments on

Statement of Reasons for Allowance."

Application/Control Number: 10/650,406

Art Unit: 2821

Inquires

Page 5

5. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Huedung Cao whose telephone number is (571) 272-

1939.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Don Wong, can be reached on (571) 272-1834. The fax phone number for

the organization where this application or proceeding is assigned is (571) 273-8300.

6. Information regarding the status of an application may be obtained from the

Patent Application Information Retrieval (PAIR) system. Status information for

published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only.

For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

July 7

**Huedung Cao** 

Patent Examiner